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THE UNIVERSITY OF TOKYO

# Development and test of an absorption bench to characterize the KAGRA mirrors R&D status report

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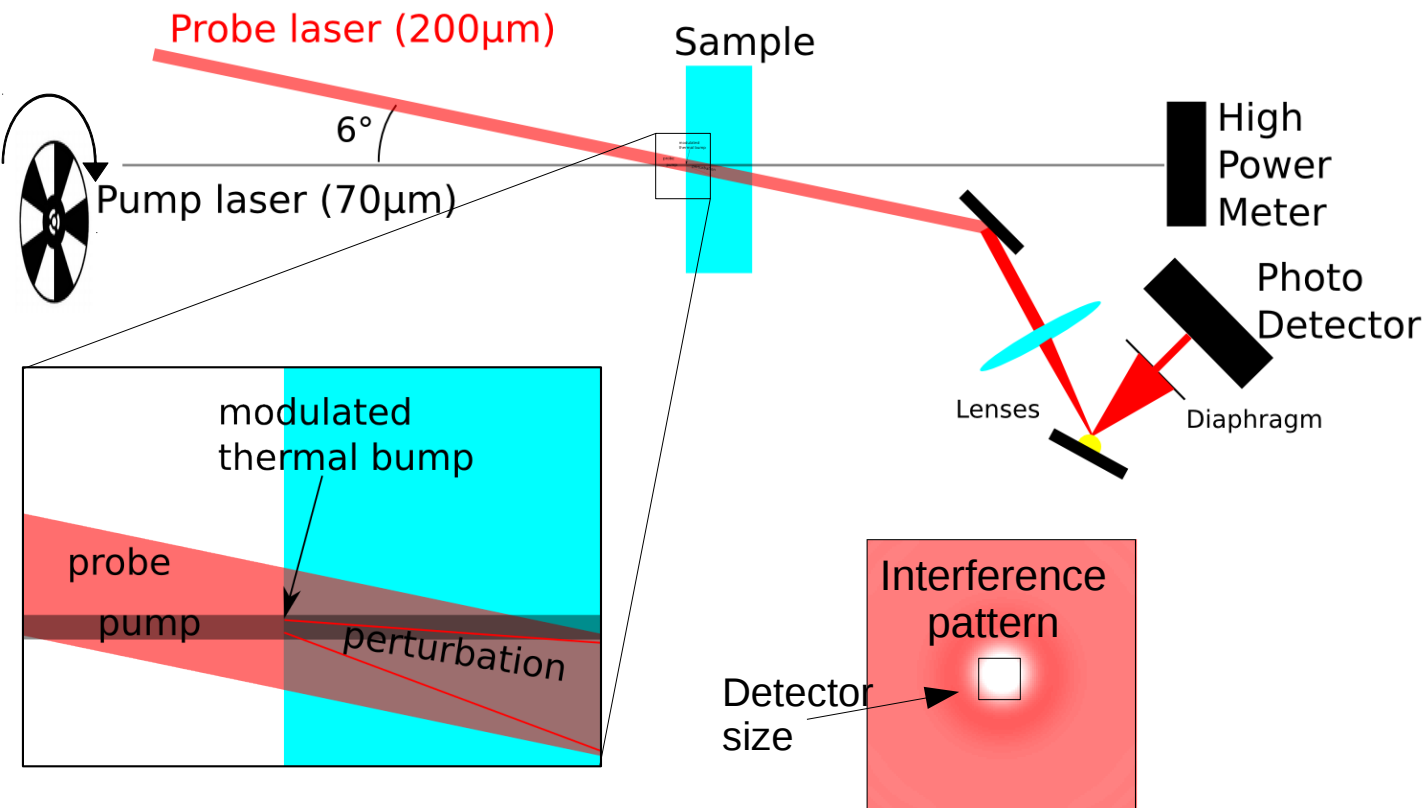
# Motivation

- The gravitational wave detector KAGRA will operate at cryogenic temperature (20K) to reduce thermal noise.
- Sapphire mirrors will be used for its good thermal properties.
- We need to minimize mirror's **optical absorption** to make cryogenic operation as easy as possible.

## HIGH REFLECTIVE COATING

- Amorphous materials have low absorption ( $<1\text{ppm}$ ) but higher mechanical losses  $\sim 10^{-4}$
- In order to reduce Brownian noise, **Crystalline coatings** are proposed for their low mechanical losses.
- Absorption and scattering need to be investigated

# Absorption measurement method at NAOJ

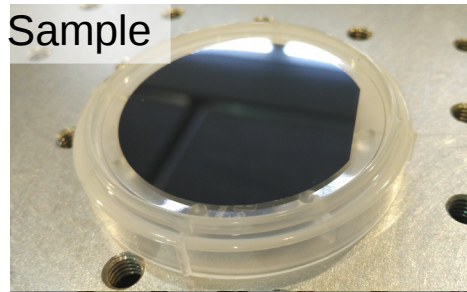


- The pump periodically changes the temperature of the sample
- The thermal lens effect changes the probe wavefront
- After some propagation, the perturbation makes interference with the main mode
- The detector sense the intensity variation of the central part of the spot.
- This variation is proportional to the pump **absorption rate**

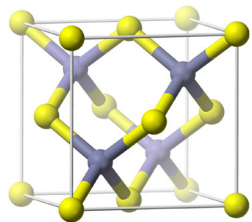
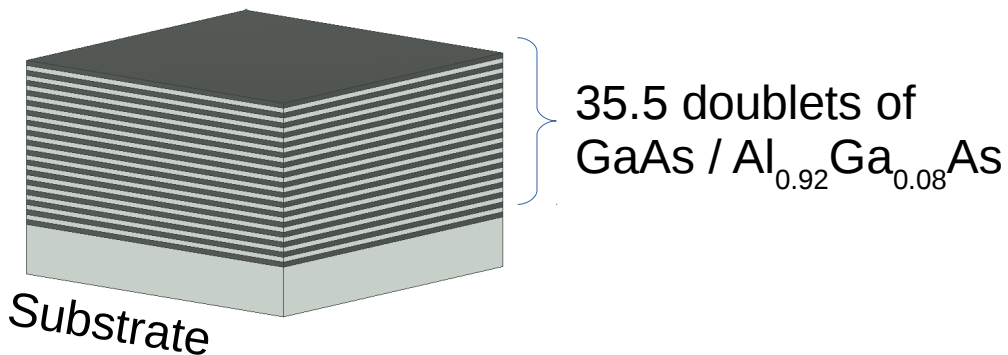
**P**hoto-thermal  
**C**ommon-path  
**I**nterferometer



# High reflective crystalline coatings



2 inches diameter



zinc blende structure

- As a KAGRA R&D activity we are doing investigation on AlGaAs crystalline coatings
- We have two samples from the company:

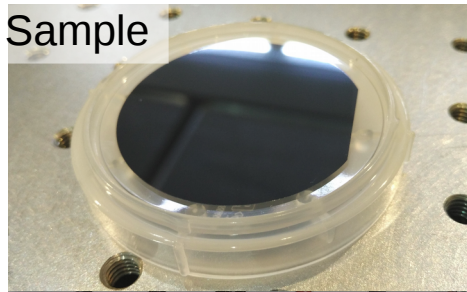


- High reflective Bragg mirror at 1064nm
- Grown with Molecular Beam Epitaxy (MBE) on a **GaAs** substrate
- Then transferred onto **silica** or **sapphire** substrate



# Transmission measurements

We have two samples



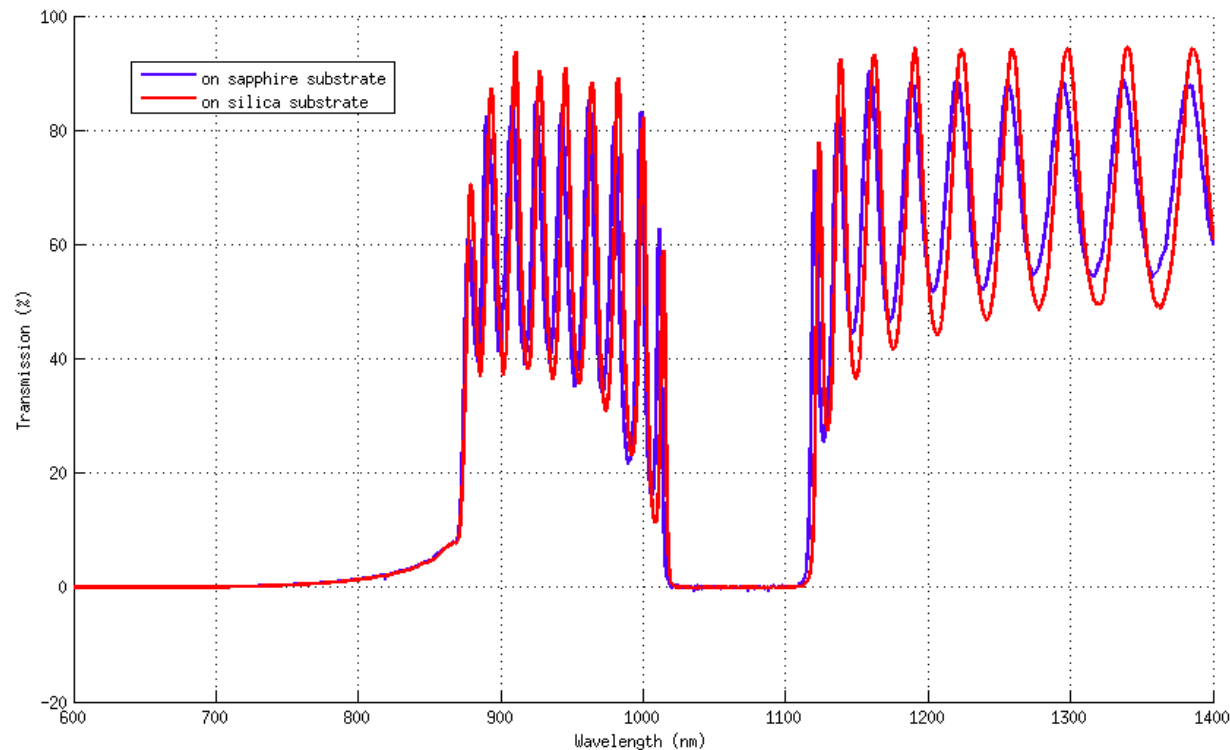
2 inches diameter

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**silica** substrate

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**sapphire** substrate

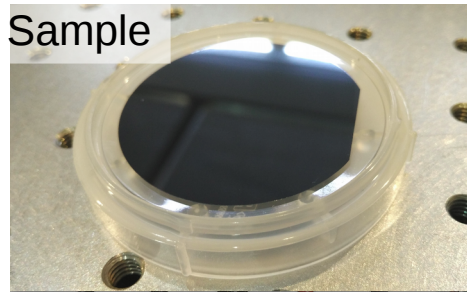
**6ppm @1064nm**

**6ppm @1064nm**



# Scattering measurements

We have two samples



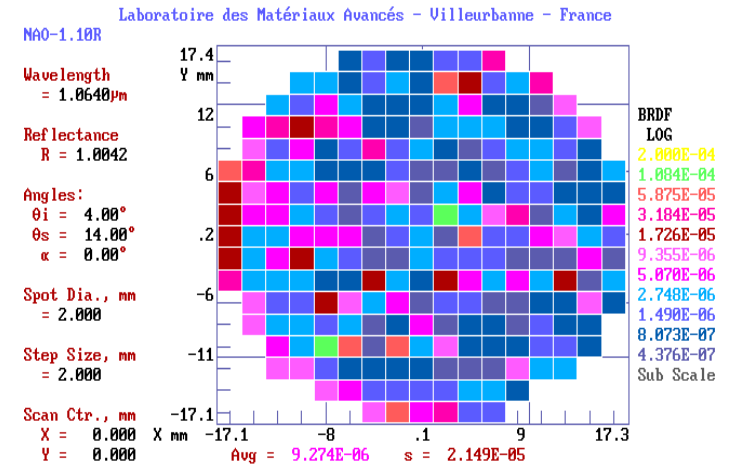
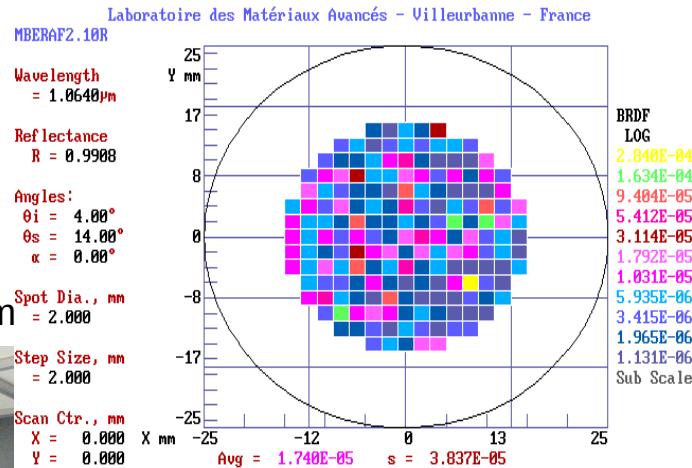
2 inches diameter

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**silica** substrate

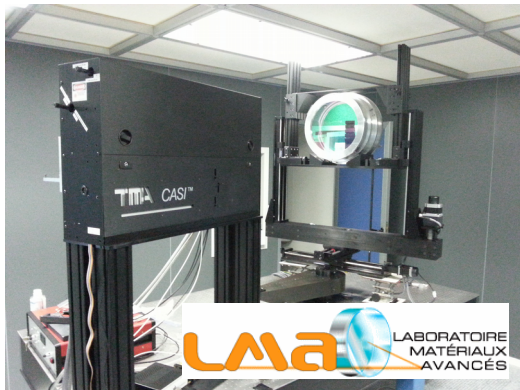
9.5 ppm

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**sapphire** substrate

6ppm

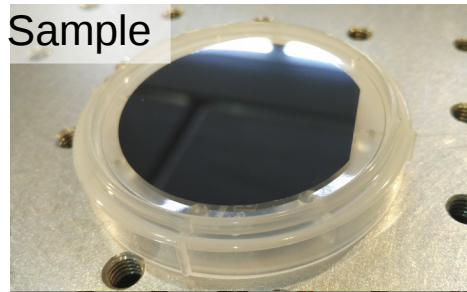


Scattering measurement system



# Roughness measurements

We have two samples

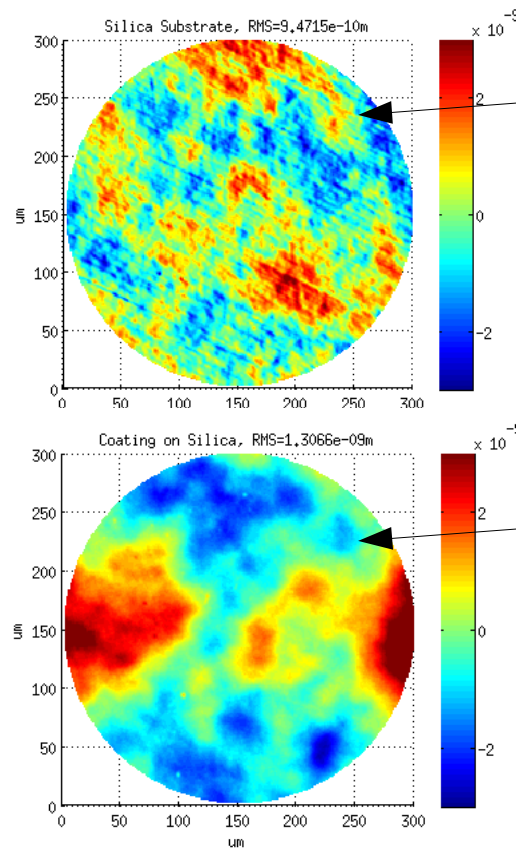


2 inches diameter

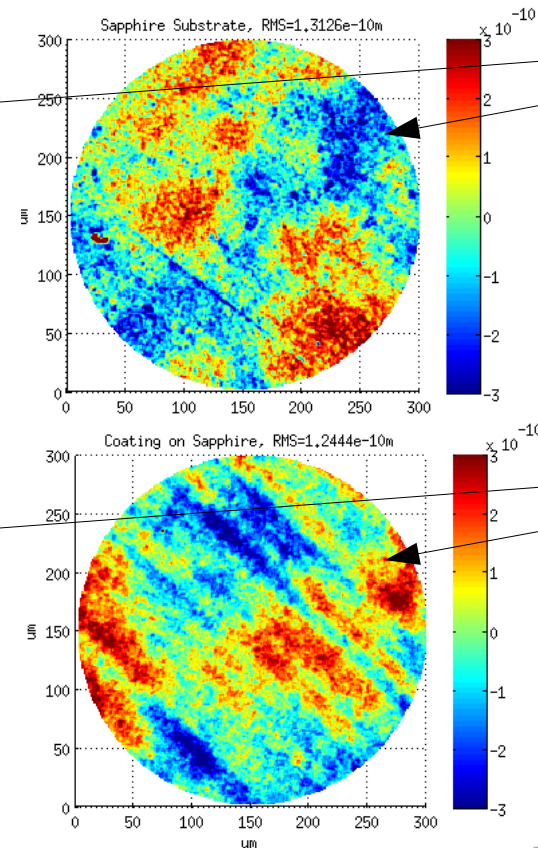
GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**silica** substrate

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**sapphire** substrate

**RMS= 1nm**

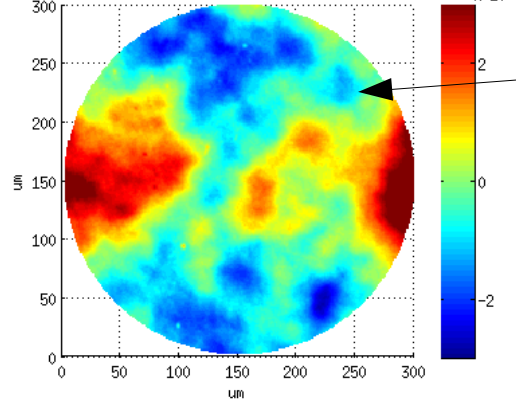


**RMS= 0.1nm**

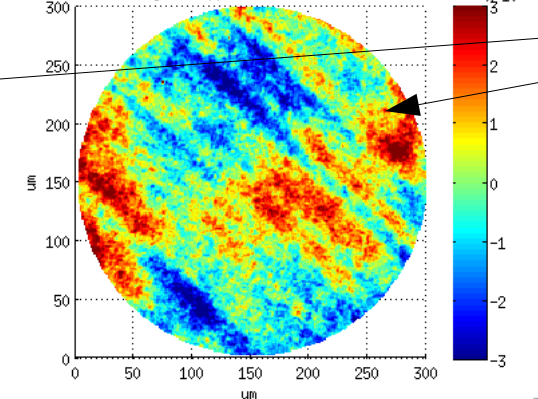


substrate

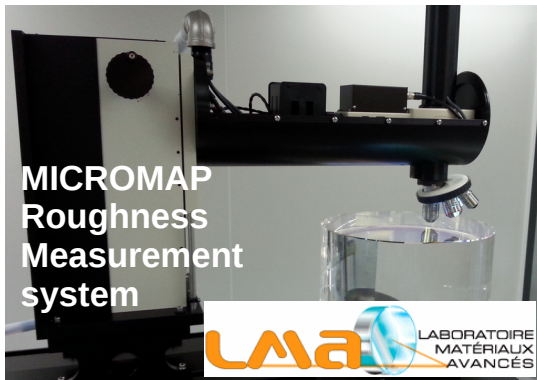
Coating on Silica, RMS=1.3066e-09m



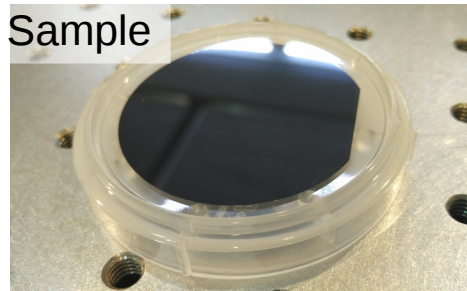
Coating on Sapphire, RMS=1.2444e-10m



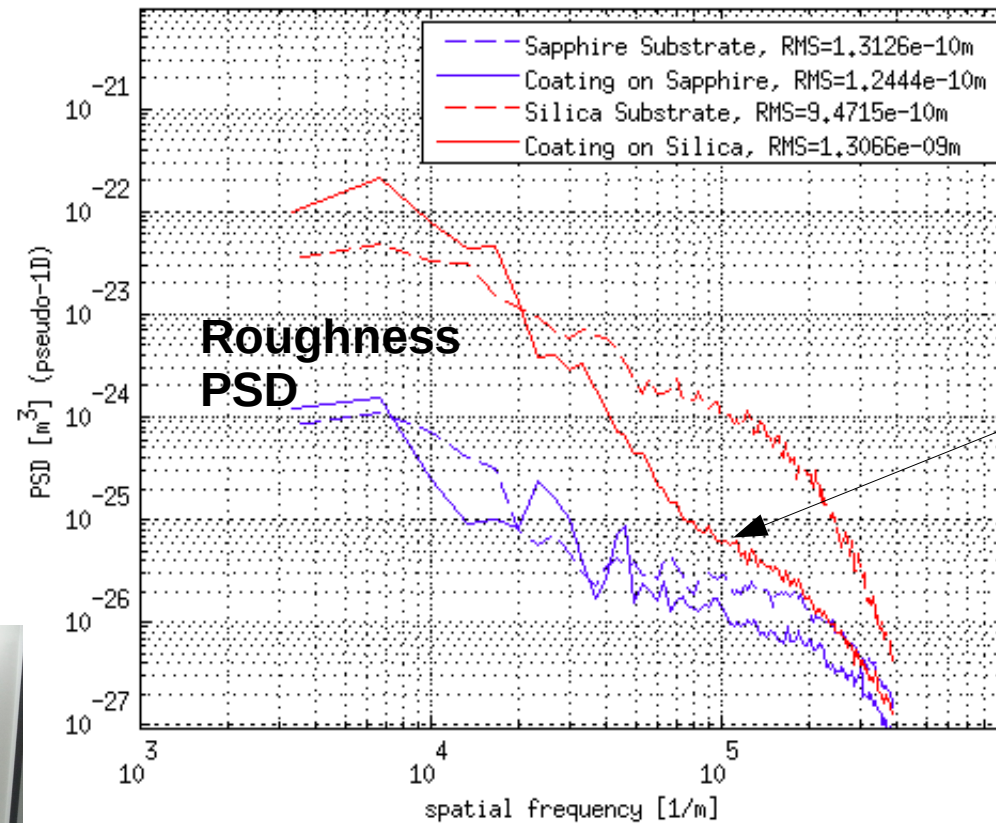
coating



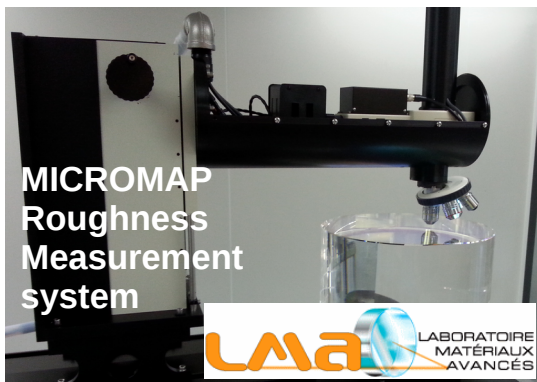
# Roughness measurements



2 inches diameter

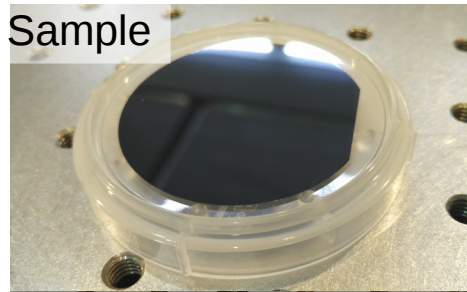


- Roughness is limited by the substrate
- Coating roughness (on silica) is lower at higher spatial frequencies





# Absorption measurements at LMA



2 inches diameter

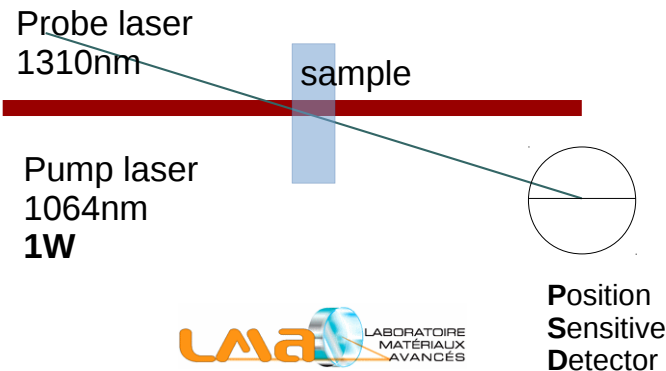
GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**silica** substrate

**0.4 ± 0.4 ppm/cm**

GaAs / Al<sub>0.92</sub>Ga<sub>0.08</sub>As  
transferred on  
**sapphire** substrate

<below noise level>

## PHOTOTHERMAL DEFLECTION METHOD



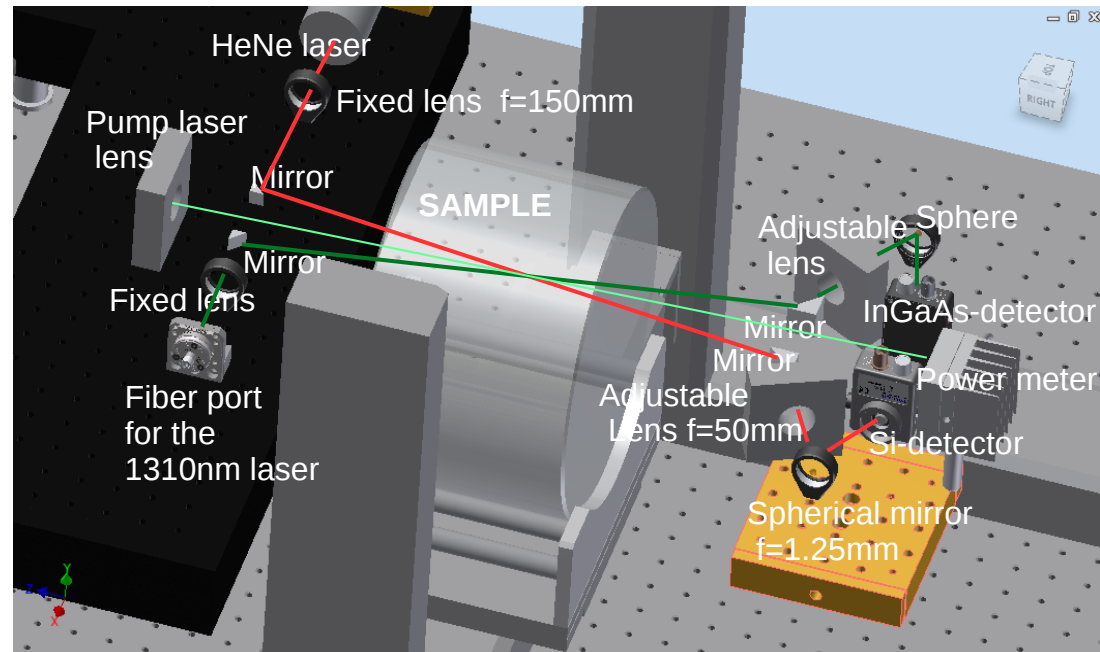
- At LMA we have a different method: instead of the focusing of the probe we measure the beam deflection
- We did single point absorption measurement
- Pump power is only 1W
- Higher thermal diffusivity of **sapphire** makes the signal too small (below the noise level)
- Low SNR → more pump power is needed

# Absorption measurements at NAOJ

- Currently installing a 1310nm probe laser



- We will be able to measure GaAs samples, which are not transparent to 633nm
- We have a 25W power pump laser, so the measurement will be more precise
- We have a translation stage to make maps of the surface absorption



Design of two probe lasers (633nm and 1310nm)



# Summary

- We have GaAs /  $\text{Al}_{0.92}\text{Ga}_{0.08}\text{As}$  coatings made by CMS company
- We did performance tests at LMA:
  - Transmission: 6ppm
  - Scattering: 6ppm and 9.5 ppm
  - Roughness: 0.1nm and 1nm (limited by the substrate)
  - Absorption: <1ppm
- We are working at NAOJ to make absorption maps with higher sensitivity
- We are installing a 1310nm probe laser



Thank you for your attention

ありがとうございました